



Call for Papers

ISPlasma2022/IC-PLANT2022

14th International Symposium on Advanced Plasma Science
and its Applications for Nitrides and Nanomaterials
15th International Conference on Plasma-Nano Technology & Science



March 6-10, 2022
Nagoya University
Nagoya, Japan



Related Fields

Plasma Science & Technologies

- Plasma Source
- Modeling & Simulation
- Thin Film Deposition Process
- Flexible Electronics
- Advanced Plasma Diagnostics
- Plasma in Liquid
- Etching Process
- Plasma for Nano & Green Technologies

Nitride Semiconductors

- Crystal Growth of GaN & Related Materials
- Characterization
- Optical & Optoelectronic Devices
- MBE Growth & Nitrogen Source
- Device Processing
- Electron & Power Devices

Nanomaterials

- Nanodots & Nanoparticles
- 2D Nanomaterials
- Composites & Functionally Graded Materials
- Applications for Energy
- Nanotubes, Nanowires & Nanorods
- Porous Materials & Membranes
- Surface Modification & Functionalization
- Nanomedicine & Sensing

Bio applications

- Plasma Biology & Medicine
- Plasma Agriculture
- Biomaterials
- Biomarkers
- Bioimaging
- Bio-Devices, uTAS, Lab on a Chip
- Biosensors
- Device Fabrication Technologies

ABSTRACT SUBMISSION DEADLINE: October 14, 2021
<http://www.isplasma.jp/>

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This conference is sponsored by The Japan Society of Applied Physics